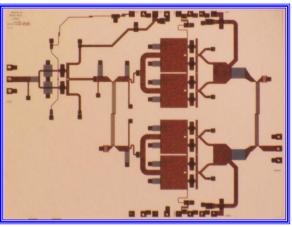


Revision: May 2014

**Preliminary Datasheet** 



X = 4.8mm Y = 3.6mm

#### **Product Features**

■ RF frequency: 27 to 31 GHz

Linear Gain: 21 dB typ.

■ Psat: 39 dBm typ.

■ Die Size: < 17.3 sq. mm.

■ 0.2um GaN HEMT Process

4 mil SiC substrate

■ DC Power: 28 VDC @ 720 mA

## **Applications**

- Point-to-Point Digital Radios
- Point-to-Multipoint Digital Radios
- SATCOM Terminals

# **Product Description**

The APN180 monolithic GaN HEMT amplifier is a broadband, two-stage power device, designed for use in SATCOM Terminals and point-to-point digital radios. To ensure rugged and reliable operation, HEMT devices are fully passivated. Both bond pad and backside metallization are Au-based that is compatible with epoxy and eutectic die attach methods.

### Performance Characteristics (Ta = 25°C)

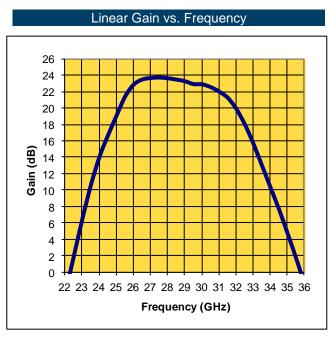
Specification	Min	Тур	Max	Unit
Frequency	27		31	GHz
Linear Gain	18	22		dB
Input Return Loss	4	8		dB
Output Return Loss	6	15		dB
P1db		37		dBm
Psat	38	39		dBm
PAE @ Psat		28		%
Vd1, Vd2=Vd2a		28		V
Vg1		-3.5		V
Vg2, Vg2a		-3.5		V
ld1		144		mA
ld2+ld2a		576		mA

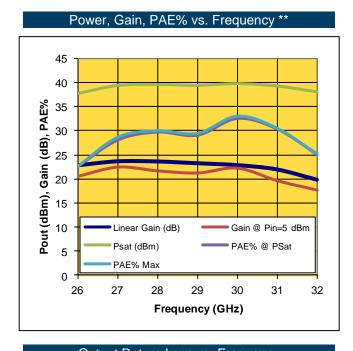
Absolute Maximum Ratings ( $Ta = 25^{\circ}C$ )

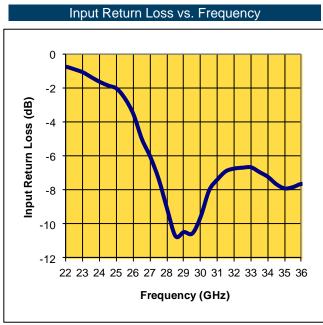
Parameter	Min	Max	Unit
Vd1, Vd2+Vd2a	20	28	V
ld1		144	mA
ld2+ld2a		576	mA
Vg1, Vg2, Vg2a	-5	0	V
Input drive level		TBD	dBm
Assy. Temperature		300	deg. C
(TBD seconds)			

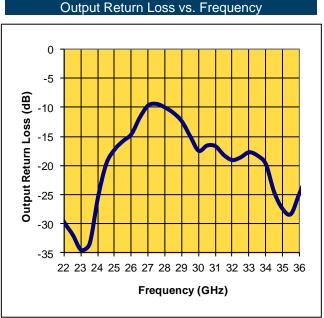


Measured Performance Characteristics (Typical Performance at 25°C) Vd = 28.0 V, Id1 = 144 mA, Id2 + Id2a = 576 mA \*





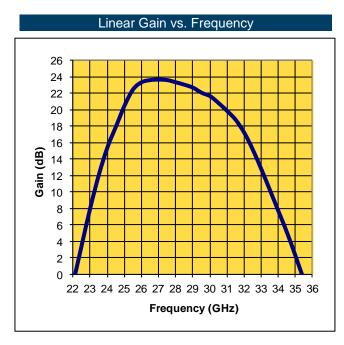


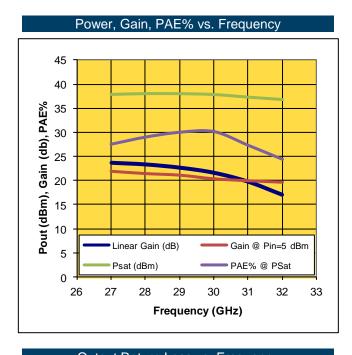


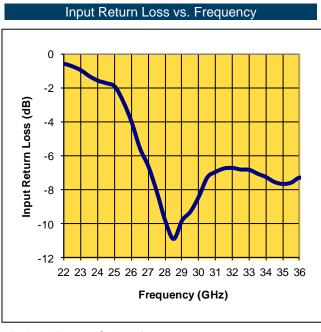
<sup>\*</sup> Pulsed-Power On-Wafer, \*\* CW Fixtured

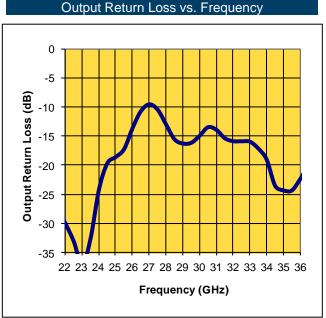


Measured Performance Characteristics (Typical Performance at 25°C) Vd = 20.0 V, Id1 = 144 mA, Id2 + Id2a = 576 mA \*





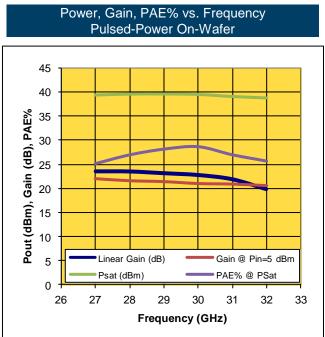


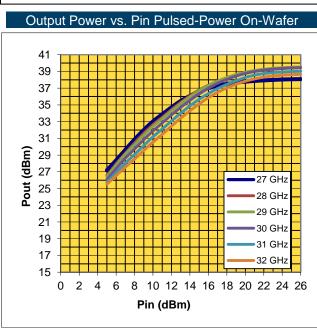


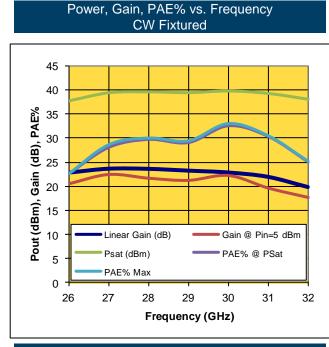
<sup>\*</sup> Pulsed-Power On-Wafer

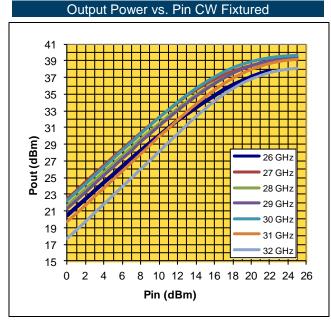


Measured Performance Characteristics (Typical Performance at 25°C) Vd = 28.0 V, Id1 = 144 mA, Id2 + Id2a = 576 mA (Quiescent)



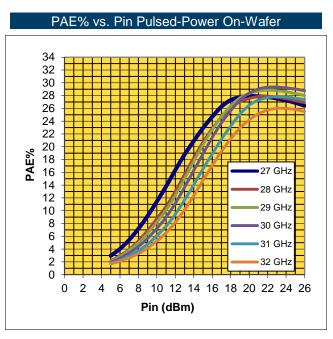


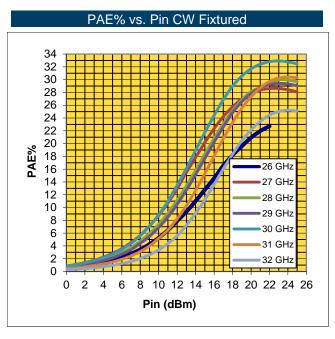


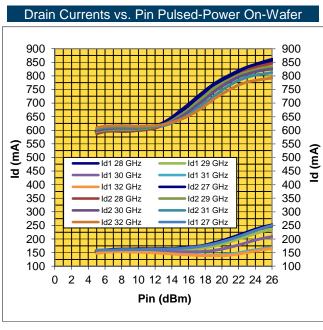


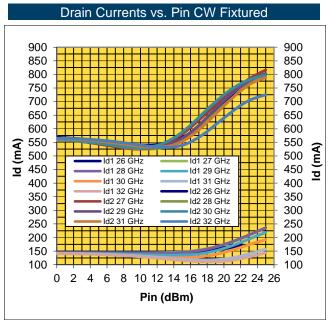


Measured Performance Characteristics (Typical Performance at 25°C) Vd = 28.0 V, Id1 = 144 mA, Id2 + Id2a = 576 mA (Quiescent)



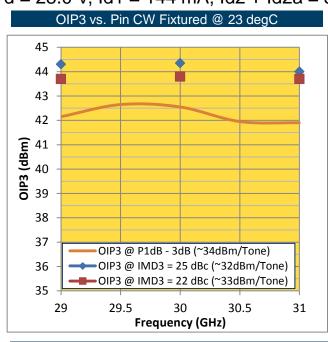


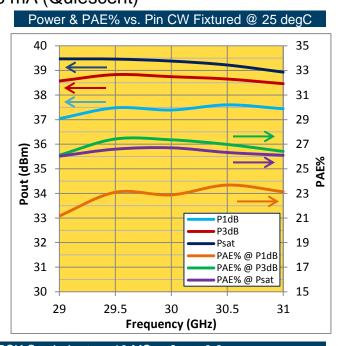


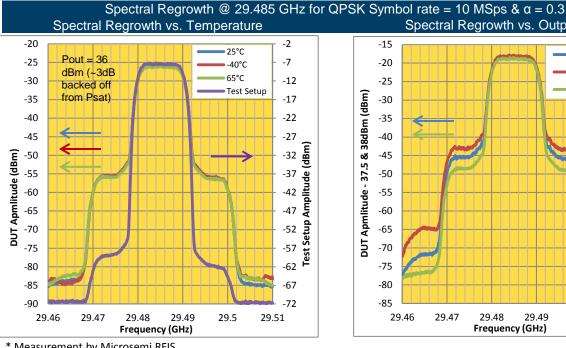


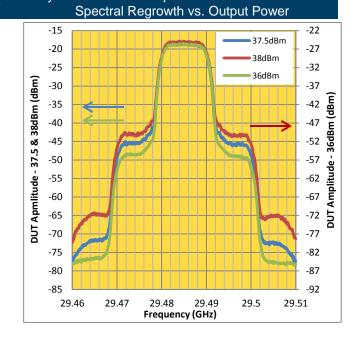


## Fixtured Measured Performance Characteristics \* Vd = 28.0 V, Id1 = 144 mA, Id2 + Id2a = 576 mA (Quiescent)





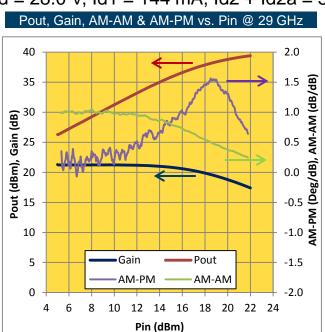


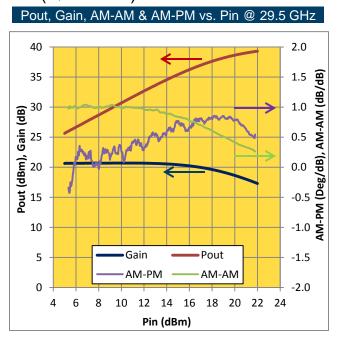


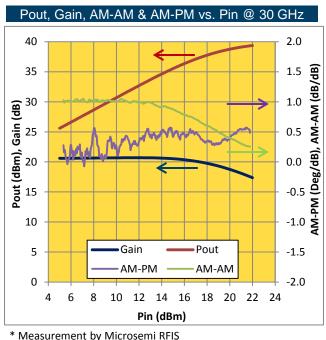
<sup>\*</sup> Measurement by Microsemi RFIS

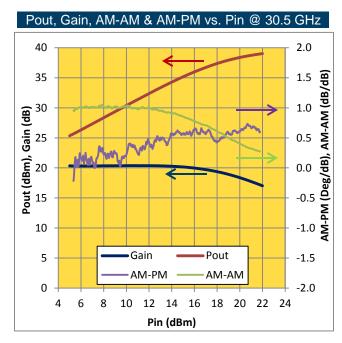


Fixtured Measured Performance Characteristics (Typical Performance at 28°C) \* Vd = 28.0 V, Id1 = 144 mA, Id2 + Id2a = 576 mA (Quiescent)







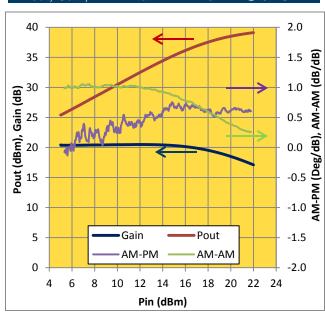


<sup>\*</sup> Measurement by Microsemi RFIS



Fixtured Measured Performance Characteristics (Typical Performance at 28°C) \* Vd = 28.0 V, Id1 = 144 mA, Id2 + Id2a = 576 mA (Quiescent)

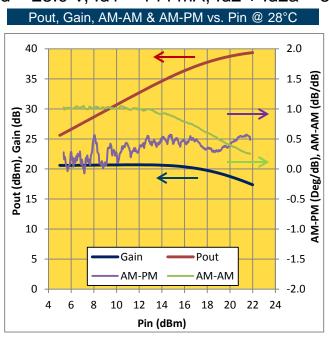
### Pout, Gain, AM-AM & AM-PM vs. Pin @ 31 GHz

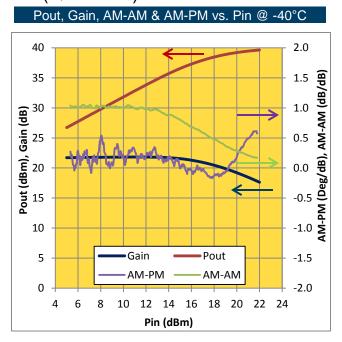


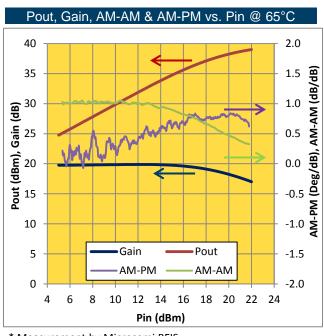
<sup>\*</sup> Measurement by Microsemi RFIS



Fixtured Measured Performance Characteristics (Typical Performance at 30 GHz) \* Vd = 28.0 V, Id1 = 144 mA, Id2 + Id2a = 576 mA (Quiescent)







<sup>\*</sup> Measurement by Microsemi RFIS



PAE% & Id Total @ Pin = 28 dBm vs. Temperature

CW Fixtured \*

1.1

0.9

0.8

0.7

0.6

0.5

0.3

0.2

0.1

Preliminary Datasheet Revision: May 2014

29

28

27

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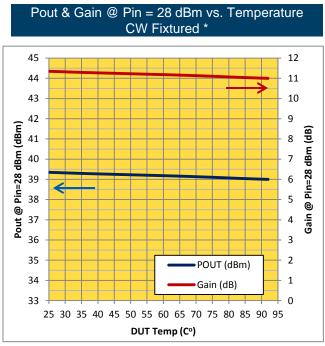
23

22

**트** 26

.@ Pin=28 c

Measured Performance Characteristics (Typical Performance at 30 GHz)\* Vd = 28.0 V, Id1 = 144 mA, Id2 + Id2a = 576 mA



35
34
33
25 30 35 40 45 50 55 60 65 70 75 80 85 90 95

DUT Temp (C°)

\* Measurement by Microsemi RFIS

Preliminary Thermal Properties with die mounted with 1mil 80/20 AuSn Eutectic to 25mil CuW Shim.

Conditions	Shim Boundary Temperature	Junction Temperature	Thermal Resistance θjc
Vd = 28V, Id1 = 209 mA *	25 °C	126.7 °C	5.1 °C/W
ld2 + ld2a = 783 mA *	50 °C	161.1 °C	5.6 °C/W
Pin=23 dBm	75 °C	195.5 °C	6.1 °C/W
Pout=39.1 dBm	78 °C **	200.0 °C	6.2 °C/W

<sup>\*</sup> Vd = 28.0 V, Idq1 = 144 mA, Id2q + Idq2a = 576 mA

<sup>\*\*</sup> Max recommended. Junction Temperatures below 200.0 °C should result in greater than 10<sup>5</sup> hours MTTF.

# APN180 27-31 GHz GaN Power Amplifier



Preliminary Datasheet Revision: May 2014

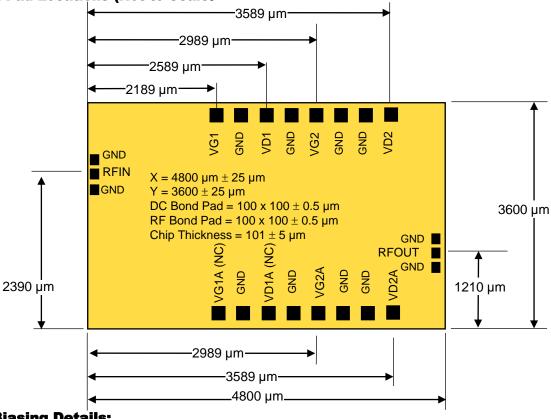
Measured Performance Characteristics (Typical Performance at 25°C) Vd = 28.0 V, Id1 = 144 mA, Id2 + Id2a = 576 mA \*

Freq GHz	S11 Mag	S11 Ang	S21 Mag	S21 Ang	S12 Mag	S12 Ang	S22 Mag	S22 Ang
21.0	0.942	55.243	0.342	-170.362	0.002	-166.716	0.065	152.524
21.5	0.939	49.587	0.575	169.383	0.002	102.340	0.069	128.941
22.0	0.927	42.768	0.985	146.926	0.002	25.226	0.072	97.324
22.5	0.919	36.102	1.746	119.542	0.001	-112.385	0.065	76.487
23.0	0.894	28.210	3.001	84.655	0.001	-100.494	0.071	69.138
23.5	0.869	21.183	4.708	44.910	0.003	-126.059	0.095	55.719
24.0	0.854	13.296	6.531	3.508	0.003	-143.553	0.128	13.894
24.5	0.860	3.075	8.767	-35.247	0.005	-166.015	0.138	-48.938
25.0	0.829	-12.305	12.056	-77.999	0.007	154.690	0.148	-149.420
25.5	0.742	-26.681	14.251	-125.030	0.010	113.037	0.217	114.136
26.0	0.681	-42.501	15.608	-169.464	0.012	77.991	0.310	50.799
26.5	0.563	-62.342	15.652	147.565	0.012	38.592	0.367	-4.431
27.0	0.510	-78.689	15.482	111.591	0.014	-4.259	0.345	-52.289
27.5	0.477	-112.272	16.535	73.417	0.015	-39.448	0.279	-91.748
28.0	0.346	-147.579	15.689	33.406	0.013	-71.339	0.228	-118.585
28.5	0.337	-175.873	15.271	-1.673	0.010	-108.775	0.172	-145.180
29.0	0.386	147.801	14.880	-39.720	0.009	-131.745	0.123	-160.979
29.5	0.400	116.981	13.787	-75.497	0.009	-171.579	0.141	-158.488
30.0	0.464	93.944	13.305	-113.217	0.010	153.075	0.144	176.390
30.5	0.505	68.594	11.930	-151.724	0.010	104.109	0.158	143.116
31.0	0.501	47.332	10.559	170.854	0.010	52.229	0.144	90.233
31.5	0.496	30.242	9.286	131.425	0.006	14.869	0.112	27.246
32.0	0.495	13.204	7.569	91.403	0.005	-2.848	0.114	-52.929
32.5	0.480	-2.780	5.701	53.350	0.008	-85.297	0.122	-116.894
33.0	0.461	-18.933	4.228	18.976	0.009	-54.974	0.121	-154.918
33.5	0.438	-34.960	3.101	-13.803	0.006	-54.679	0.105	176.278
34.0	0.432	-48.536	2.253	-46.308	0.002	-82.565	0.088	148.306
34.5	0.429	-65.327	1.634	-78.439	0.007	-95.224	0.057	140.691
35.0	0.422	-78.700	1.145	-109.625	0.005	35.783	0.039	166.011
35.5	0.416	-93.589	0.759	-138.612	0.006	-164.566	0.062	159.310
36.0	0.426	-107.407	0.524	-164.513	0.004	33.354	0.076	170.766
36.5	0.435	-119.646	0.348	168.028	0.005	-27.297	0.085	163.096
37.0	0.459	-131.475	0.217	144.145	0.003	-56.007	0.092	144.691

<sup>\*</sup> Pulsed-Power On-Wafer



### Die Size and Bond Pad Locations (Not to Scale)



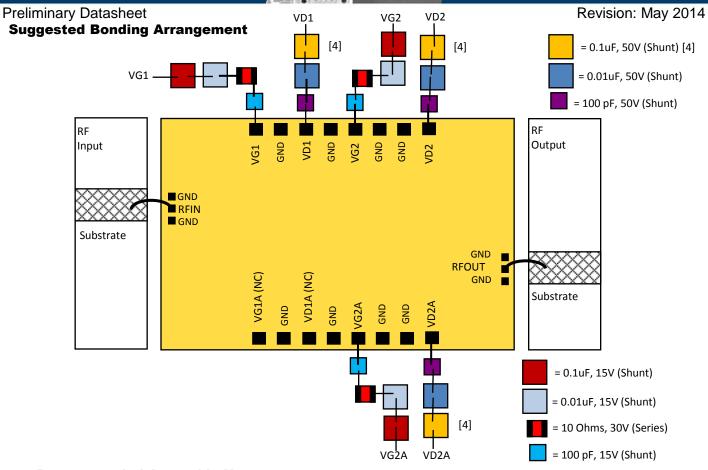
### **Biasing/De-Biasing Details:**

Bias for 1st stage is from top. The 2nd stages must bias up from both sides.

Listed below are some guidelines for GaN device testing and wire bonding:

- a. Limit positive gate bias (G-S or G-D) to < 1V
- b. Know your devices' breakdown voltages
- c. Use a power supply with both voltage and current limit.
- d. With the power supply off and the voltage and current levels at minimum, attach the ground lead to your test fixture.
  - i. Apply negative gate voltage (-5 V) to ensure that all devices are off
  - ii. Ramp up drain bias to ~10 V
  - iii. Gradually increase gate bias voltage while monitoring drain current until 20% of the operating current is achieved
  - iv. Ramp up drain to operating bias
  - Gradually increase gate bias voltage while monitoring drain current until the operating current is achieved
- e. To safely de-bias GaN devices, start by debiasing output amplifier stages first (if applicable):
  - i. Gradually decrease drain bias to 0 V.
  - ii. Gradually decrease gate bias to 0 V.
  - iii. Turn off supply voltages
- f. Repeat de-bias procedure for each amplifier stage





#### **Recommended Assembly Notes**

- 1. Bypass caps should be 100 pF (approximately) ceramic (single-layer) placed no farther than 30 mils from the amplifier.
- 2. Best performance obtained from use of <10 mil (long) by 3 by 0.5 mil ribbons on input and output.
- 3. Part must be biased from both sides as indicated.
- 4. The 0.1uF, 50V capacitors are not needed if the drain supply line is clean. If Drain Pulsing of the device is to be used, do **NOT** use the 0.1uF, 50V Capacitors.

### **Mounting Processes**

Most NGAS GaN IC chips have a gold backing and can be mounted successfully using either a conductive epoxy or AuSn attachment. NGAS recommends the use of AuSn for high power devices to provide a good thermal path and a good RF path to ground. Maximum recommended temp during die attach is 320°C for 30 seconds.

**Note**: Many of the NGAS parts do incorporate airbridges, so caution should be used when determining the pick up tool.

**CAUTION**: THE IMPROPER USE OF AUSn ATTACHMENT CAN CATASTROPHICALLY DAMAGE GaN CHIPS.

# PLEASE ALSO REFER TO OUR "Gan Chip Handling Application Note" BEFORE HANDLING, ASSEMBLING OR BIASING THESE MMICS!

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